

FIG. 1

Substrate temperature (°C)	20	30	40	50	60	70
Rate of defective spreading of solvent (%)	5	0	0	0	0	0

FIG. 2

Substrate temperature (°C)	20	30	40	50	60	70
Ratio of nozzles (%)	0	0	0	0	0	7

FIG. 3

Substrate temperature (°C)	20	30	40	50	60	70	80
Rate of defective spreading of solvent (%)	5	0	0	0	0	0	0
Rate of defective aggregation of spacer (%)	3	0	0	0	0	2	5

FIG. 4

Substrate temperature (°C)	20	30	40	50	60	70	80
Ratio of nozzles (%)	0	0	0	0	0	12	32

FIG. 5

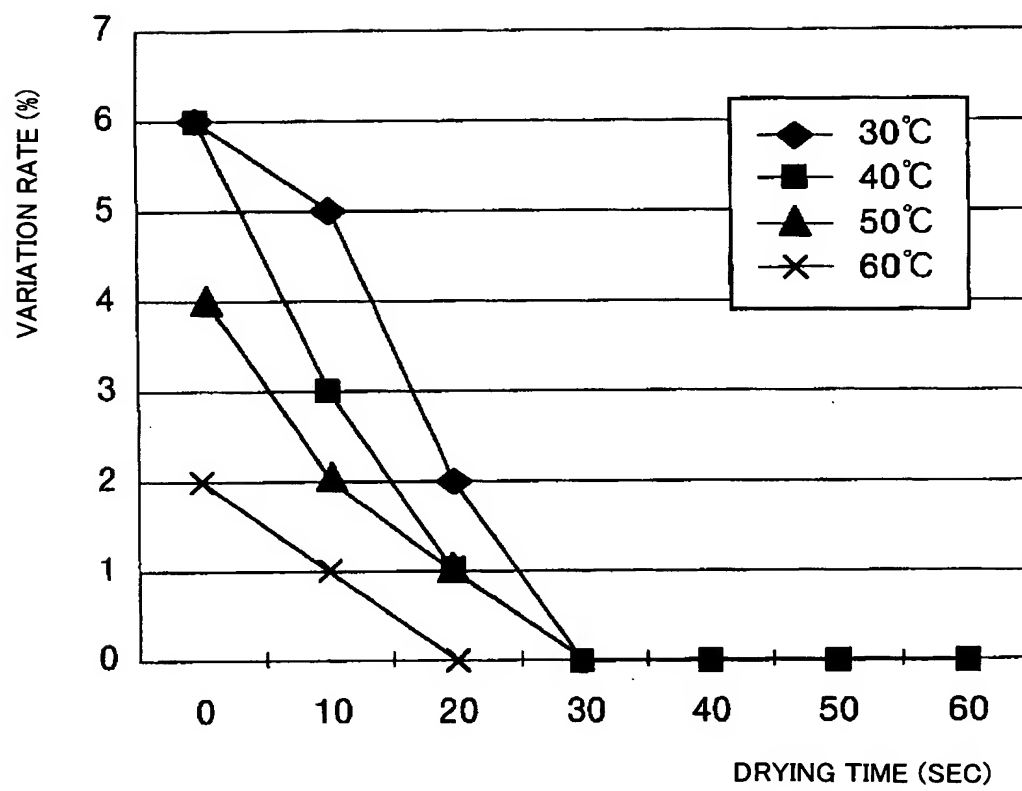


FIG. 6

